Application Areas

Aerospace

- Drilling acoustic damping holes (ø 200 μm)
- Drilling cooling holes in ceramic coated metals (ø 1 mm)

Solar Energy

- Drilling & scribing silicon wafer
- Crystallisation & annealing

Automotive

- Drilling fuel cells (ø 20 μm)
- Material treatment

Semiconductors

- Silicon wafer drilling
- Surface selective roughening
- Percussion drilling



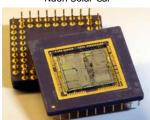
GLARE fuselage and leading edges panels for Airbus A380



Advanced solar panels



Nuon Solar Car



Novel semiconductors manufacturing

Task? The solution!

If you are interested in cooperation, please contact

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TU Delft

Sirius Laser Facility

Structural Integrity & Composites (SI&C) Group

Faculty of Aerospace Engineering

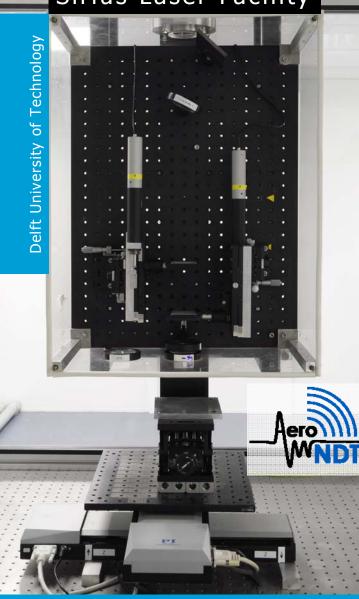
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Delft Sirius Laser Facility Objective

Research and innovation of advanced aerospace, automotive and semiconductors materials

About the Sirius Laser

Sirius 1000 Laser is a 1 kW excimer laser, which generates 1 J pulses at an optical wavelength of 308 nm. The pulse length is 200 ns and the maximum energy density is greater than 5 Jcm⁻². The laser has a very good beam profile over a 28 mm beam diameter.

The laser was developed for laser drilling and surface modification of materials.

Use of the Facility

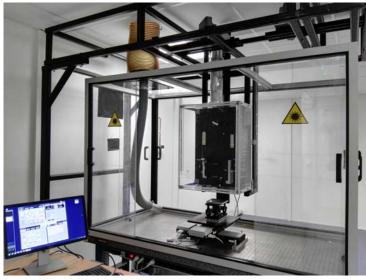
The Delft Sirius Laser Facility is open for commercial and research activities. The laser can drill many types of materials, including composites and metals, with hole sizes are in the range 10 μ m to 1 mm. The power and beam profile are adjustable for material modification. Automated stages allow controlled material modification and drilling of sample hole patterns across samples up to 500 mm length, later to be extended to 2 m.

Our offer is

- ☐ Industry projects
- ☐ Collaboration in national and international research projects
- Education and student projects

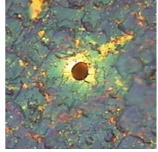


Operation Space

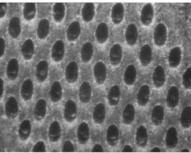


Laser processing area 1 (maximum object dimensions are $500\times200\times100$ mm) Beam operation area 2 for objects with dimensions $2000\times1000\times500$ mm is under construction

Applications



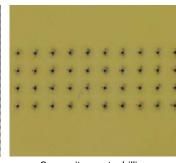
Silicon wafer drilling



Fuel cells drilling



Acoustic damping holes drilling



Composites parts drilling